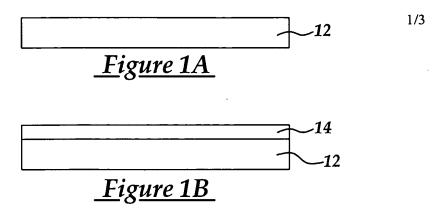
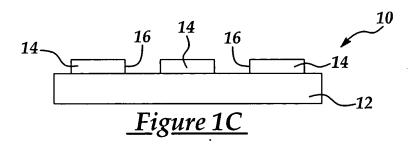
Inventor: CHING-YU CHANG

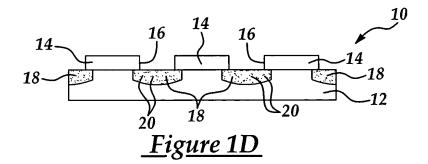
Serial No.: To Be Assigned Filed: Herewith

For: ESD-Resistant Photomask And Method Of Preventing Mask ESD Damage

Attorney Doc. No.: 67,200-1262







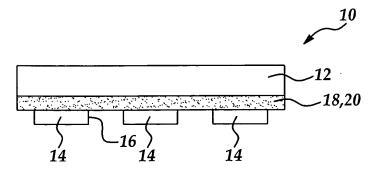


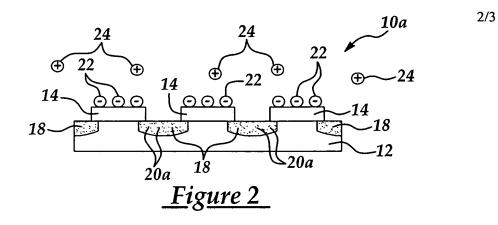
Figure 1E

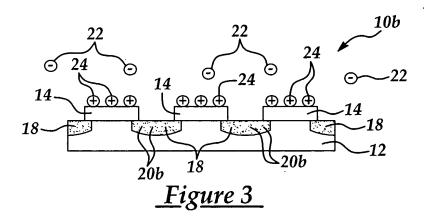
Inventor: CHING-YU CHANG

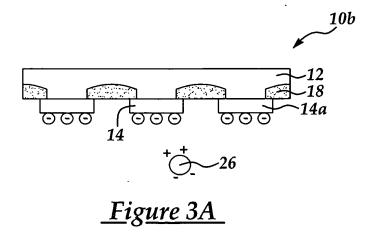
Serial No.: To Be Assigned Filed: Herewith

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Attorney Doc. No.: 67,200-1262



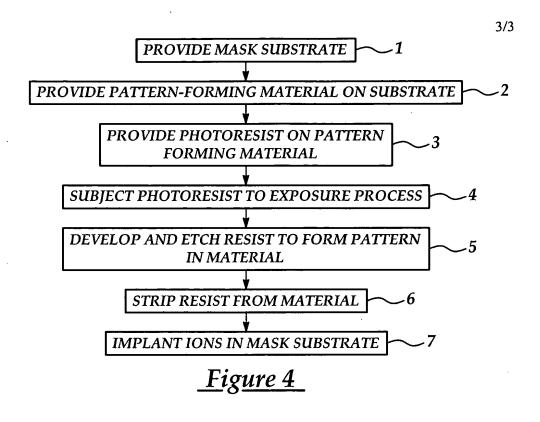




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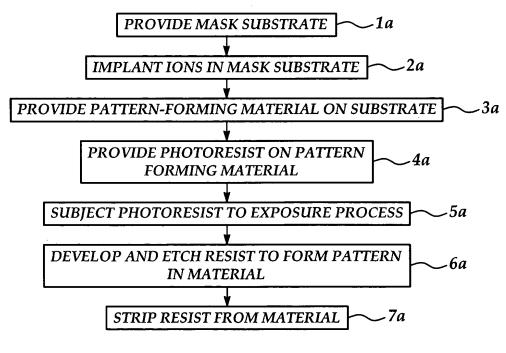


Figure 5